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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/775,712	02/09/2004	Connie C. Liu	SEA-2845.1	3832
36521 75	90 01/09/2006		EXAMINER	
MOSER, PATTERSON & SHERIDAN LLP/			RICKMAN, HOLLY C	
U	CHNOLOGY LLC BURY AVENUE		ART UNIT PAPER NUMBER	
SUITE 100			1773	
SHREWSBURY, NJ 07702			DATE MAILED: 01/09/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
•	10/775,712	LIU ET AL.				
Office Action Summary	Examiner	Art Unit				
	Holly Rickman	1773				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address						
Period for Reply A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING I - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period. - Failure to reply within the set or extended period for reply will, by statu. Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATIO .136(a). In no event, however, may a reply be tind it will apply and will expire SIX (6) MONTHS from te, cause the application to become ABANDONE	N. mely filed the mailing date of this co				
Status						
Responsive to communication(s) filed on <u>24 (</u> This action is FINAL . 2b) ☐ This action is application is in condition for allowed closed in accordance with the practice under	is action is non-final. ance except for formal matters, pr		e merits is			
Disposition of Claims						
4) Claim(s) 1-5,13 and 15-21 is/are pending in the day of the above claim(s) 1-5,13 and 15 is/are 5) Claim(s) is/are allowed. 6) Claim(s) 16-21 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/	e withdrawn from consideration.					
Application Papers						
9) The specification is objected to by the Examin 10) The drawing(s) filed on is/are: a) ac Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the E	cepted or b) objected to by the edrawing(s) be held in abeyance. Section is required if the drawing(s) is ob-	ee 37 CFR 1.85(a). ojected to. See 37 Cl				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreig a) All b) Some * c) None of: 1. Certified copies of the priority documer 2. Certified copies of the priority documer 3. Copies of the certified copies of the pri application from the International Bures * See the attached detailed Office action for a list	nts have been received. nts have been received in Applicat ority documents have been receiv au (PCT Rule 17.2(a)).	tion No red in this National	Stage			
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summar Paper No(s)/Mail D 5) Notice of Informal 6) Other:	Date	O-152)			

DETAILED ACTION

Claim Rejections - 35 USC § 112

1. The rejection of claim 17 under 35 U.S.C. 112, second paragraph, is withdrawn in view of Applicant's amendments.

Claim Objections

2. Claim 17 is objected to under 37 CFR 1.75(c), as being of improper dependent form for failing to further limit the subject matter of a previous claim. Applicant is required to cancel the claim(s), or amend the claim(s) to place the claim(s) in proper dependent form, or rewrite the claim(s) in independent form. Claim 16 requires that the bottom surface of the composite nickel coating is in contact with the non-magnetic substrate. Thus, claim 17 does not further limit claim 16.

Claim Rejections - 35 USC § 103

- 3. The rejection of claims 16-17 under 35 U.S.C. 103(a) as being unpatentable over Ross et al. (US 5980997) is withdrawn in view of Applicant's amendments and arguments.
- 4. Claims 16-21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chen et al. (US 5153044).

Chen et al. disclose a magnetic recording disk having a substrate with a first layer of NiP in contact with the substrate and a second layer of NiP thereon with a magnetic recording layer and protective layer thereon (see Fig 1). The reference fails to disclose a first Ni coating layer

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that is "sputter deposited" and a second Ni coating layer that is "electrolessly deposited." These limitations are process limitations in an article claim and are therefore, considered only insofar as they add distinguish the present claims in a structural or material manner over the prior art. It is the examiner's contention that claimed deposition methods do not materially or structurally distinguish the present claims over Chen et al.

With respect to the claimed surface roughness(Ra) range, Chen et al. teach that it is preferred in their invention to provide a NiP surface that is uniform (i.e., smooth) in order to create a magnetic recording layer having a uniform crystalline structure (see col. 5, lines 53-57 and col. 6, lines 14-28). While the reference is silent with respect to the specific values of Ra that correspond to this above mentioned disclosure, it is the Examiner's position that the reference is suggestive of a range of Ra that is as low as 0Δ . The reference teaches the preferred use of a smooth surface (i.e., this would ideally be 0Δ). Thus, it would have been a matter of routine experimentation for one of ordinary skill in the art to adjust the Ra of the NiP surface taught by Ross et al. to meet the disclosed surface requirements.

With respect to the limitations "non-polished" (see claim 16), the examiner takes the position that Chen et al. discloses a non-polished NiP layer because it teaches a method of forming the structure that does not include a polishing step in between deposition of the second NiP layer and the overlying magnetic layer. In any event, this limitation is a process limitation in an article claim. Because the product taught by the prior art appears to be the same as the claimed product, these limitations do not patentably distinguish the present claims over what is known in the art.

Even though product-by-process claims are limited and defined by the process, determination of patentability is based on the product itself. The patentability of a product does not depend on its method of production. If the product in the product-by-process claim is the same as or obvious from a product of the prior art, the claim is unpatentable even though the prior product was made by a different process. *In re Thorpe*, 777 F.2d 695, 698, 227 USPQ 964, 966 (Fed. Cir. 1985).

Response to Arguments

- 5. Applicant's arguments filed 10/24/05 have been fully considered but they are moot in view of the new grounds of rejection.
- 6. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

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7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Holly Rickman whose telephone number is (571) 272-1514. The examiner can normally be reached on Monday-Friday 9:30-6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carol Chaney can be reached on (571) 272-1284. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Holly Rickman Primary Examiner Art Unit 1773